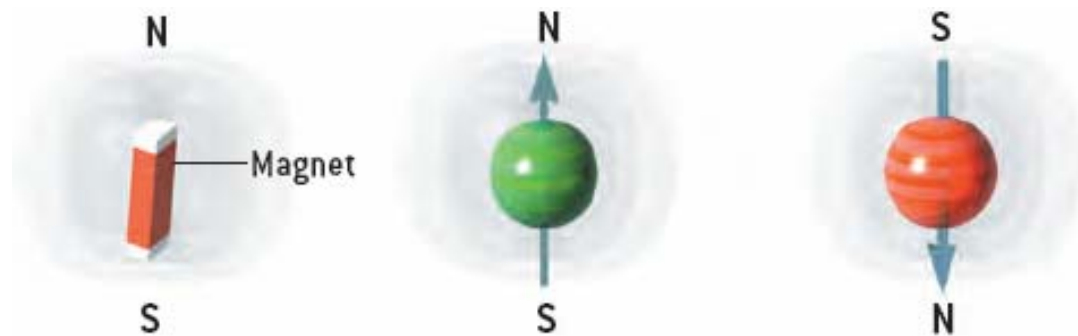

Single Spin Magnetic Resonance and Related Phenomena in Si Field Effect Transistors



or how to measure a single electron spin

Ivar Martin

*June 2006,
KITP, UCSB*

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Acknowledgements

- *D. Mozyrsky (LANL, T-4)*
- *M. Hastings (LANL, T-13)*
- *A. Shnirman (Karlsruhe)*
- *Experiment: H.W. Jiang's group at UCLA*

REFS:	<i>Phys. Rev. Lett.</i> 90 , 018301 (2003)	-	ESR - theoretical scheme
	<i>Phys. Rev. Lett.</i> 91 , 078301 (2003)	-	experiment (B-dep)
	<i>Nature</i> 430 , 435 (2004)	-	experiment (1 spin ESR)
	<i>Phys. Rev. B</i> 71 , 165115 (2005)	-	Kondo + lattice
	cond-mat/0312503	-	Fermi-edge + lattice
	<i>Phys. Rev. B</i> 73 , 035104 (2006)	-	polaronic molecular switch

Introduction: Single Spin Magnetic Resonance

Random Telegraph Noise in Field Effect Transistors

- *A scheme for Electron Spin Resonance: Theory*
- *A scheme for Electron Spin Resonance: Experiment*
- *Single Spin Measurement*

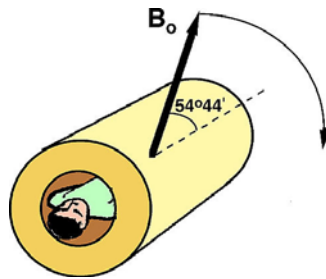
Inconsistency between expected and observed tunneling rates: Polaronic slowdown

Low temperature magnetic anomalies: Possible Kondo Effect

Summary and Open problems

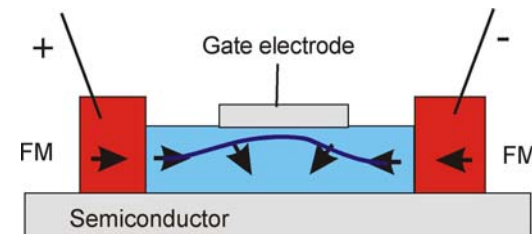
Applications of Spin measurement

Magnetic Resonance Imaging (MRI)



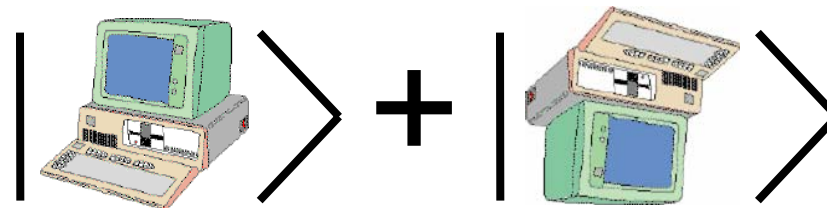
$> 10^{10}$ spins

Spin – Effect Devices (Spin Transistors)



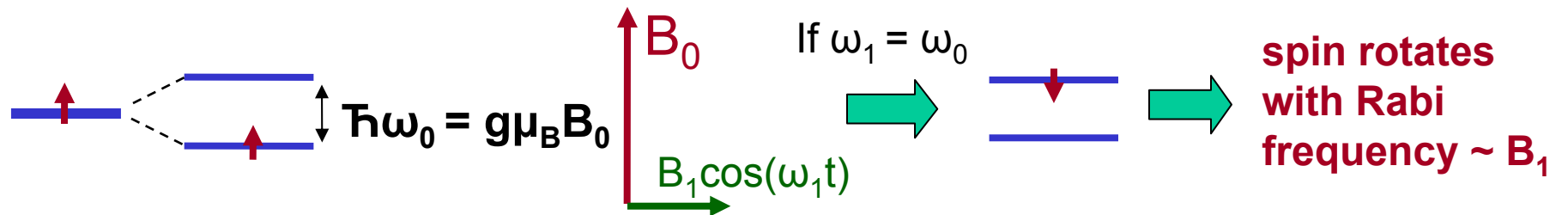
$> 10^3$ spins

Quantum Computing

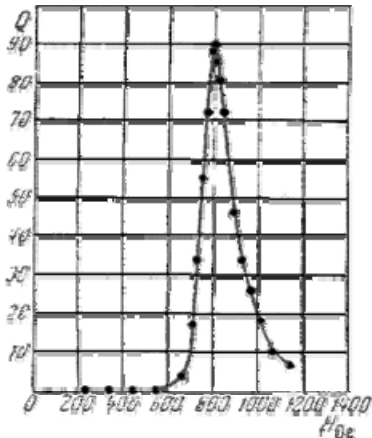


1 spin

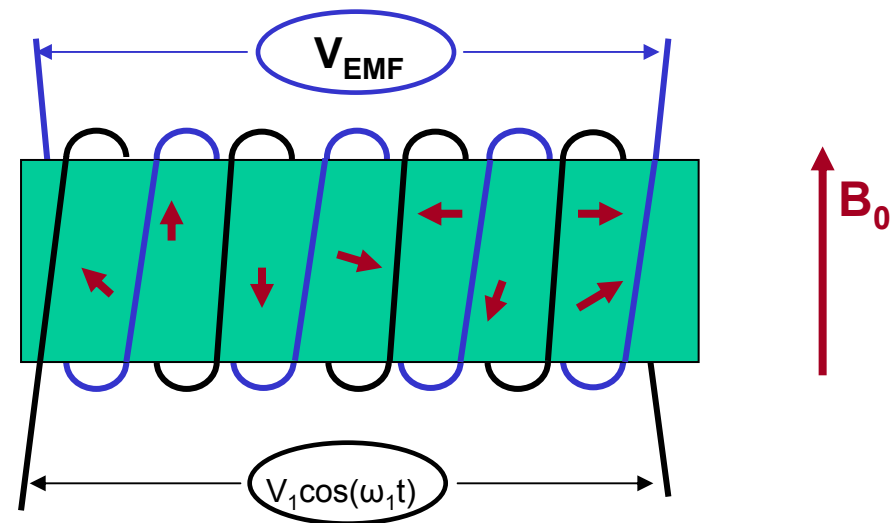
Electron Spin Resonance



Experiment

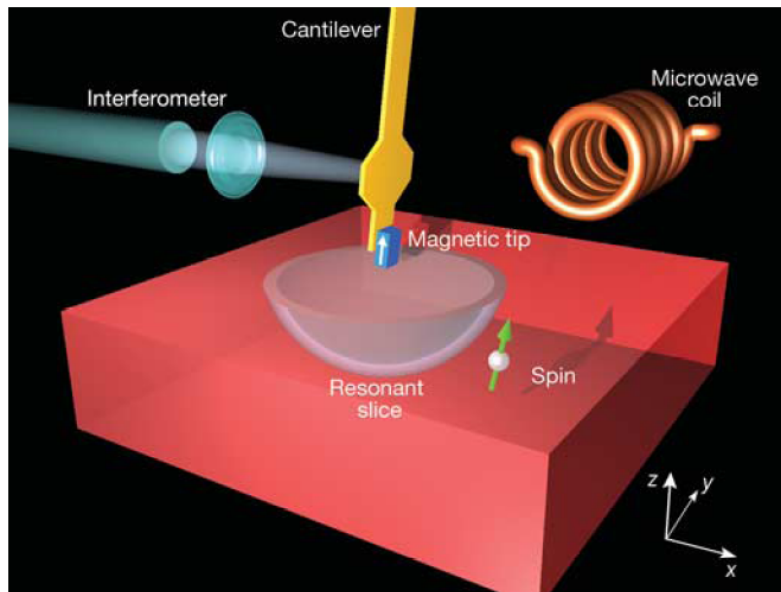


Rabi, Zacharias, Millman, Kusch (1939)



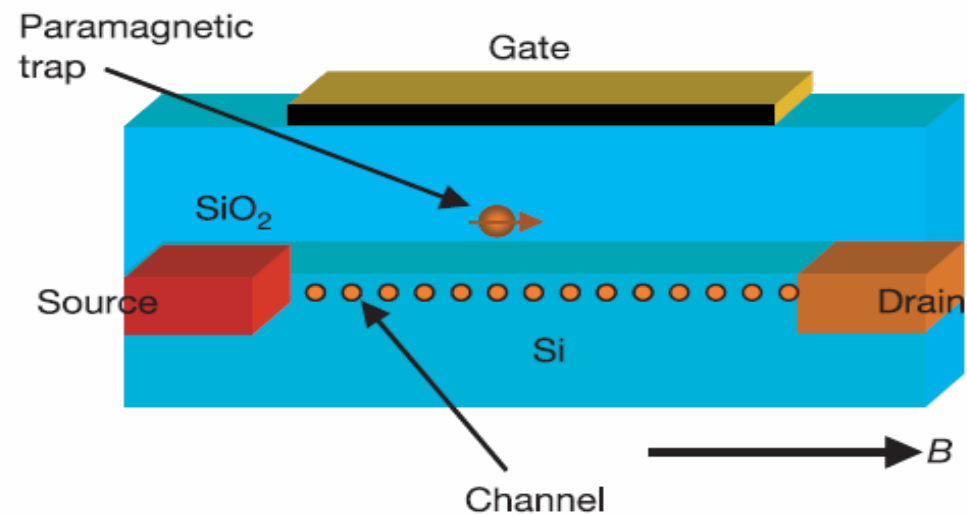
Single Spin Resonance: MRFM and Paramagnetic Traps in FETs

Magnetic Resonance Force Microscopy (MRFM)



Rugar, Budakian, Mamin & Chui,
Nature 430, 329 (2004)

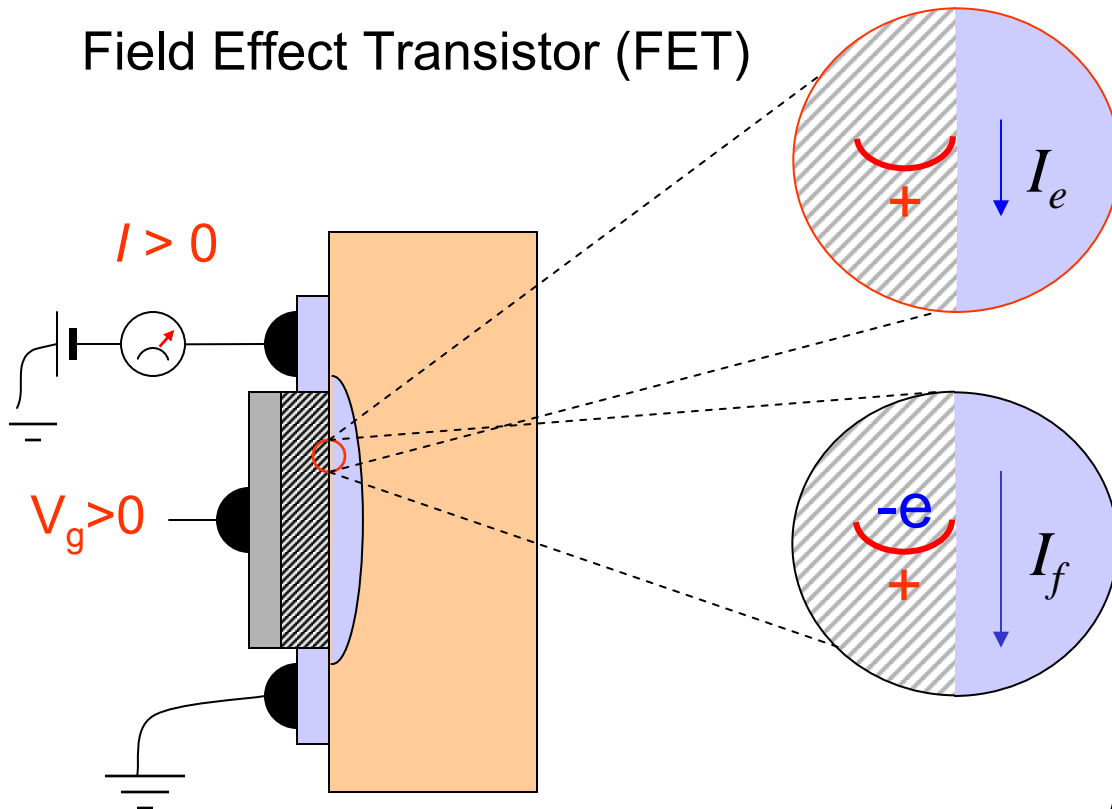
Electron Spin Resonance in a Field Effect Transistor (FET)



Xiao, Martin, Yablonovitch & Jiang,
Nature 430, 435 (2004)

Traps in Field Effect Transistors and Random Telegraph Signals

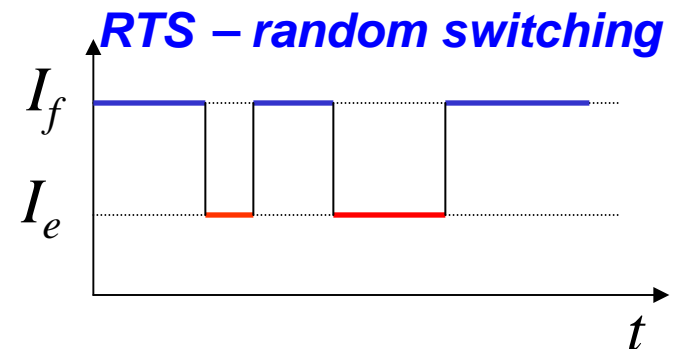
Field Effect Transistor (FET)



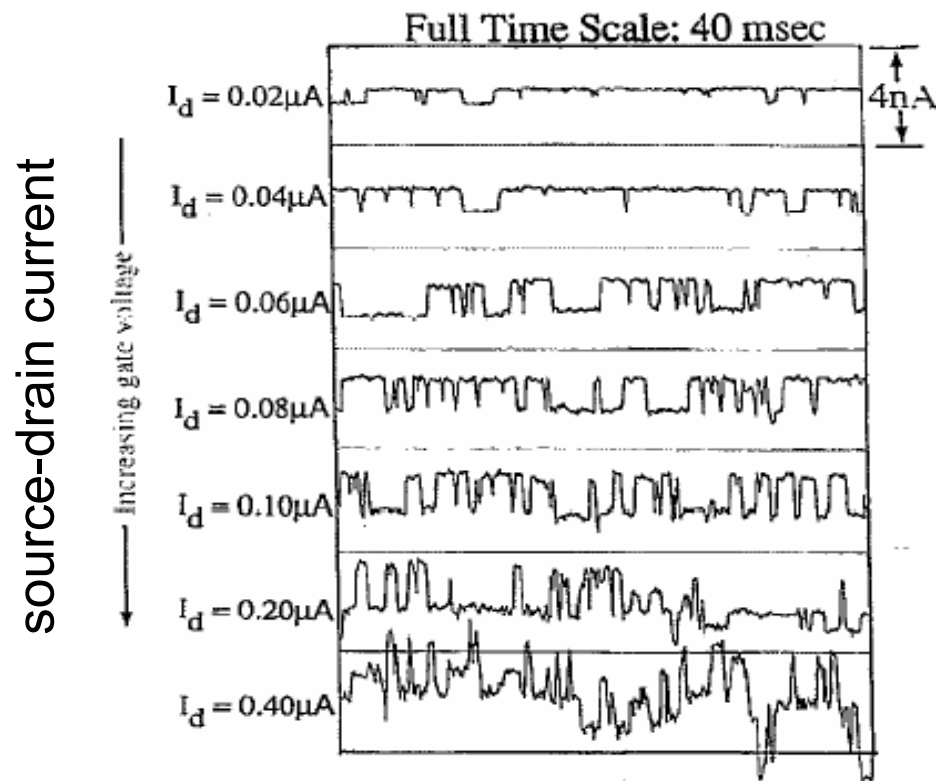
empty trap (**positive**)
higher resistance

or

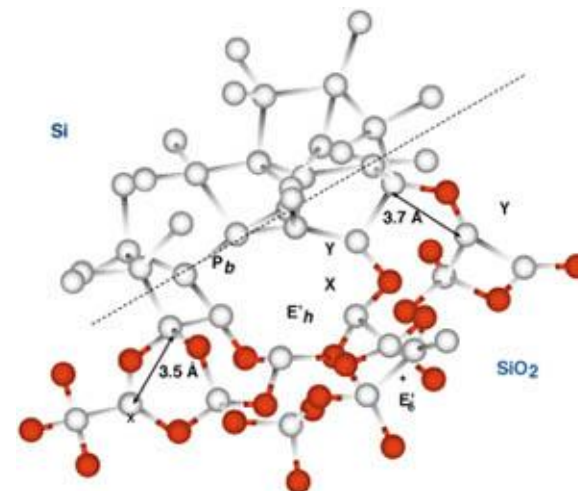
filled trap (**neutral**)
lower resistance



Random Telegraph Signal (RTS) - experiment



Defects at Si - SiO₂ interface



Ming-Horn Tsai, Hirotaka Muto,^{a)} and T. P. Ma
 Appl. Phys. Lett. 61 (14), 5 October 1992

A Setup for Electron Spin Resonance (ESR)

At $T = 0$, $B_1 = 0$:

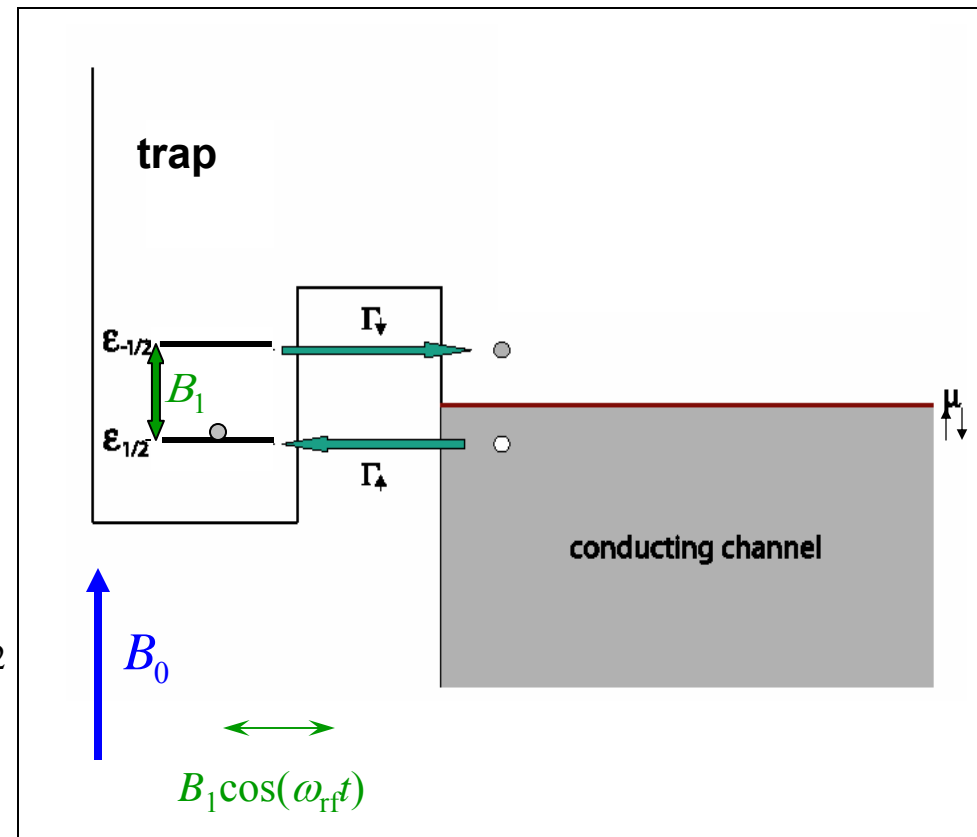
trap is filled if $\epsilon_{1/2} < \mu$
 trap is empty if $\epsilon_{1/2} > \mu$

No RTS

At $T = 0$ and resonant $B_1(t)$:

trap can be filled if $\epsilon_{-1/2} < \mu$
 e^- is promoted $\epsilon_{1/2} \rightarrow \epsilon_{-1/2}$
 e^- can escape if $\epsilon_{1/2} > \mu$

Electron Spin Resonance
-induced RTS!



The trap occupation number is *modified* by resonant $B_1(t)$

Quantum rate equations for ESR-RTS

I. Martin, D. Mozyrsky & H.-W. Jiang, Phys. Rev. Lett. 90, 018301 (2003)

$$H = \sum_s \left(\epsilon_s n_s + \frac{U}{2} n_s n_{-s} \right) + \sum_{q,s} \epsilon_{qs} c_{qs}^\dagger c_{qs} + \sum_{q,s} T_q (c_{qs}^\dagger c_s + c_s^\dagger c_{qs}) + H_{\text{rf}}(t).$$

$$H_{\text{rf}}(t) = \frac{\omega_R}{2} \left(c_{1/2}^\dagger c_{-1/2} e^{i\omega_{\text{rf}} t} + h.c. \right) \quad \text{– rotating wave approx}$$

$$\dot{\sigma}_0 = -\Gamma_{\uparrow} \sigma_0 + \Gamma_{\downarrow} \sigma_{\downarrow\downarrow},$$

$$\dot{\sigma}_{\uparrow\uparrow} = \Gamma_{\uparrow} \sigma_0 + i(\omega_R/2) (e^{i\omega_{\text{rf}} t} \sigma_{\uparrow\downarrow} - e^{-i\omega_{\text{rf}} t} \sigma_{\downarrow\uparrow}),$$

$$\dot{\sigma}_{\downarrow\downarrow} = -\Gamma_{\downarrow} \sigma_{\downarrow\downarrow} - i(\omega_R/2) (e^{i\omega_{\text{rf}} t} \sigma_{\uparrow\downarrow} - e^{-i\omega_{\text{rf}} t} \sigma_{\downarrow\uparrow}),$$

$$\dot{\sigma}_{\uparrow\downarrow} = -i(E/\hbar) \sigma_{\uparrow\downarrow} - \Gamma_{\downarrow}/2 \sigma_{\uparrow\downarrow} + i(\omega_R/2) e^{-i\omega_{\text{rf}} t} (\sigma_{\uparrow\uparrow} - \sigma_{\downarrow\downarrow}).$$

equations of motion
for trap density matrix

$$\boxed{\sigma_0 + \sigma_{\uparrow\uparrow} + \sigma_{\downarrow\downarrow} = 1}$$

Average FET channel resistivity:

$$\boxed{\rho = \rho_e \sigma_0 + \rho_f (1 - \sigma_0)}$$

Resonance in average resistance

$$\rho(B_0) = \rho_f + \frac{(\rho_e - \rho_f) \omega_R^2}{4(g\mu_B B_0/\hbar - \omega_{\text{rf}})^2 + \Gamma^2 + 3\omega_R^2}$$

Application of resonant rf $B_1(t)$ modifies the average channel resistivity by changing the RTS **statistics**

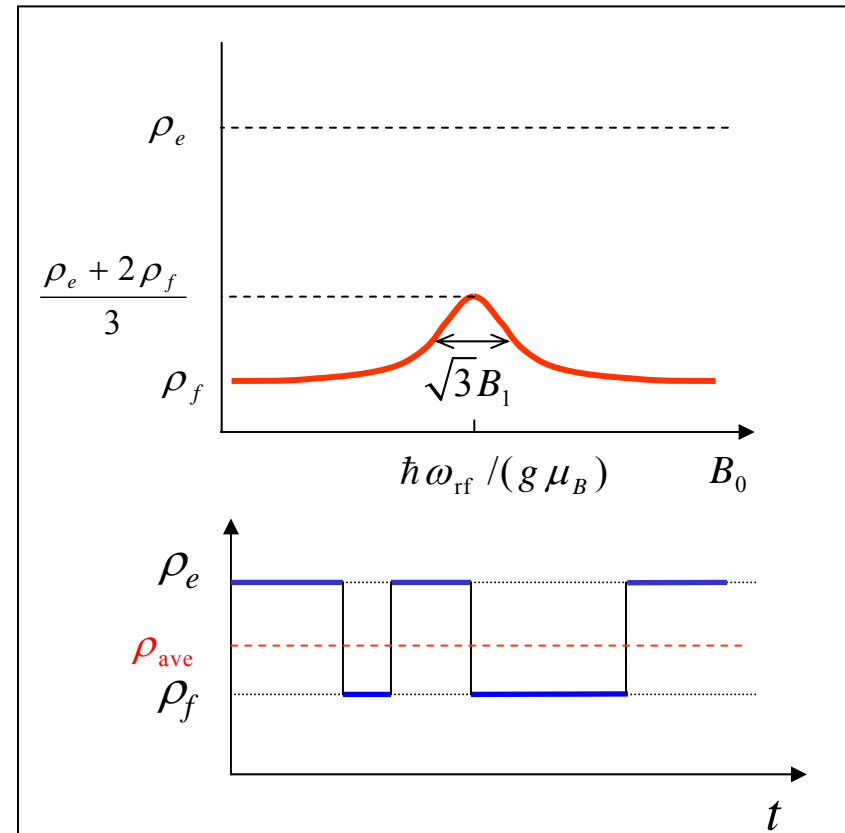
In presence of dephasing
 $1/T_2' \gg \Gamma$:

peak width:

$$(1/T_2') \sqrt{1 + 3\omega_R^2 T_2' / (2\Gamma)}$$

peak height:

$$1/[3 + 2\Gamma/(\omega_R^2 T_2')]$$

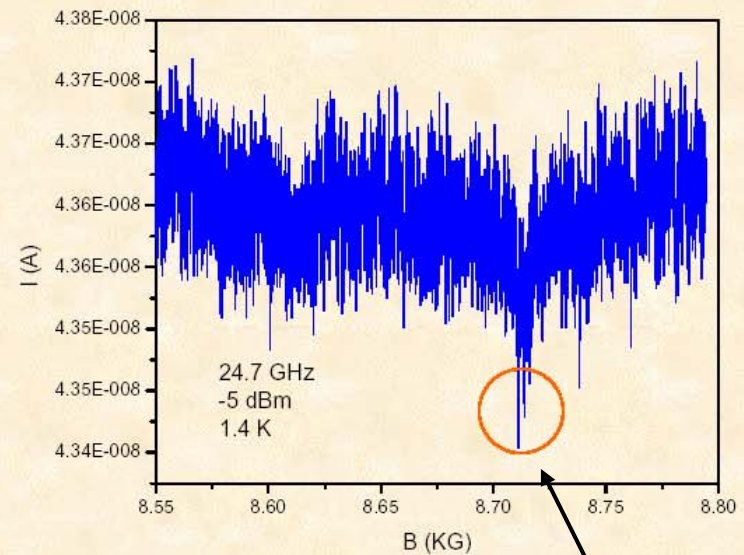
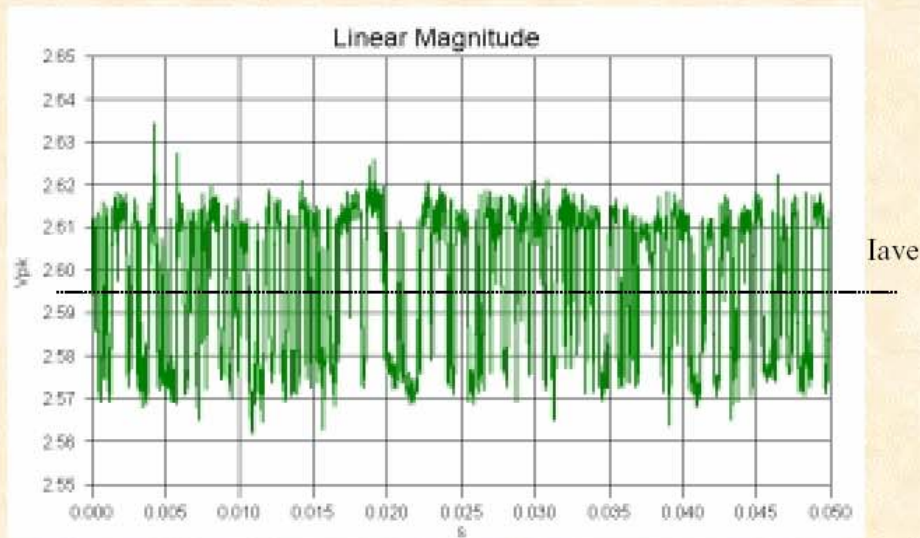


ESR-RTS Experiment - average current

(M. Xiao et al., Nature 430, 435, 2004)

Measure average current: reflects the statistical occupation change:

$$I_{avr} = I_h * p_h + I_l * p_l$$

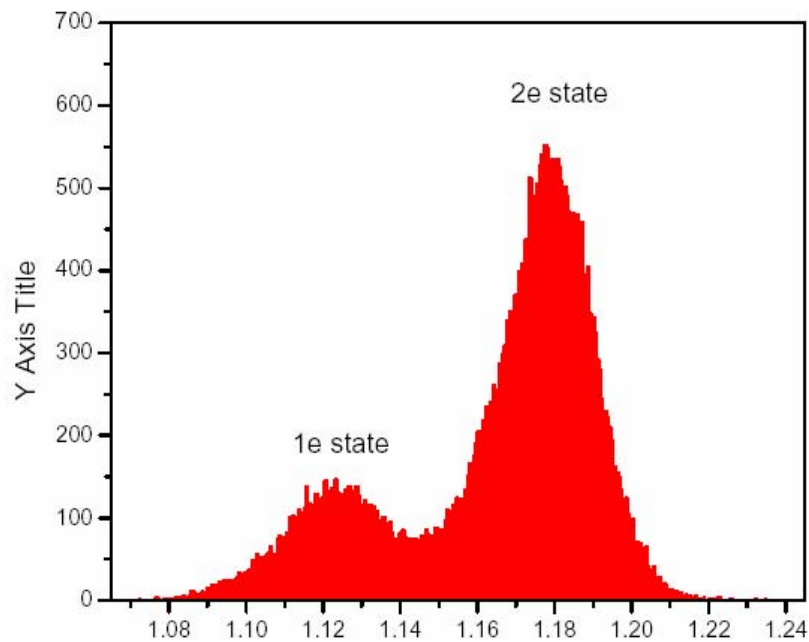


$g = 2.02$

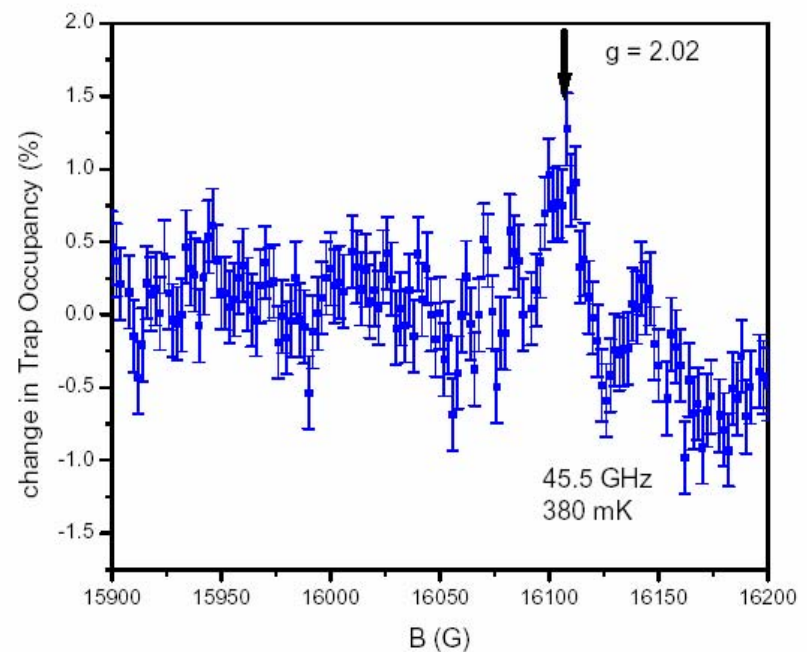
Only observed in the RTS region.

ESR-RTS Experiment – trap occupancy (HWJ)

Observed a change in the trap occupation probability

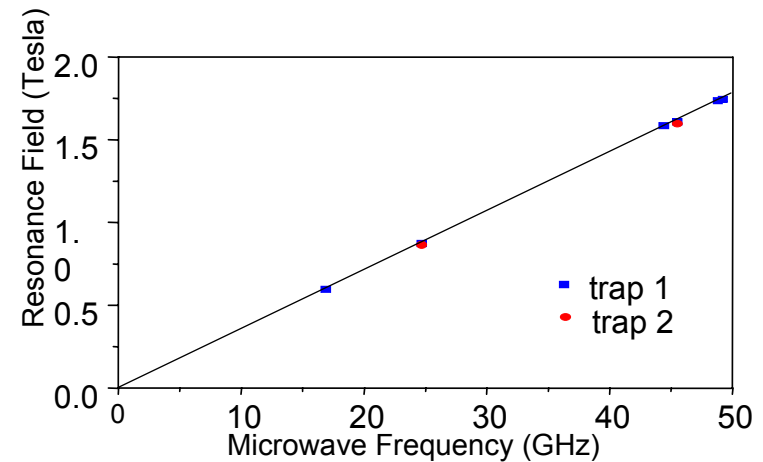
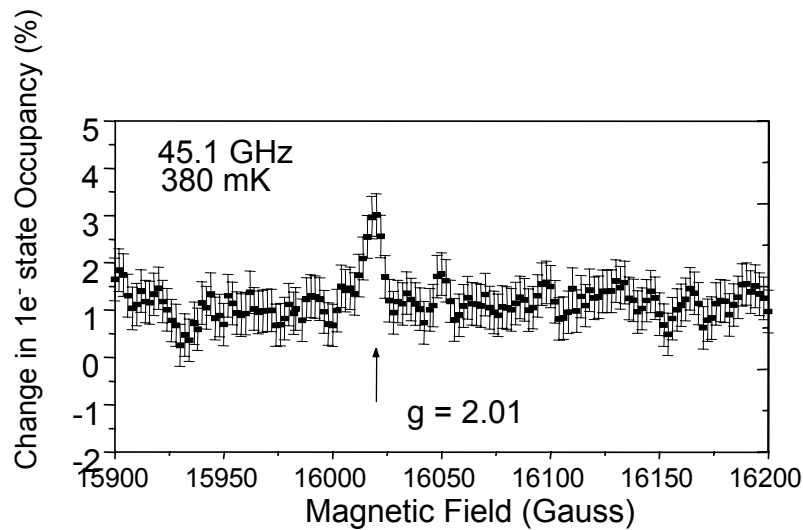


histogram of the raw data



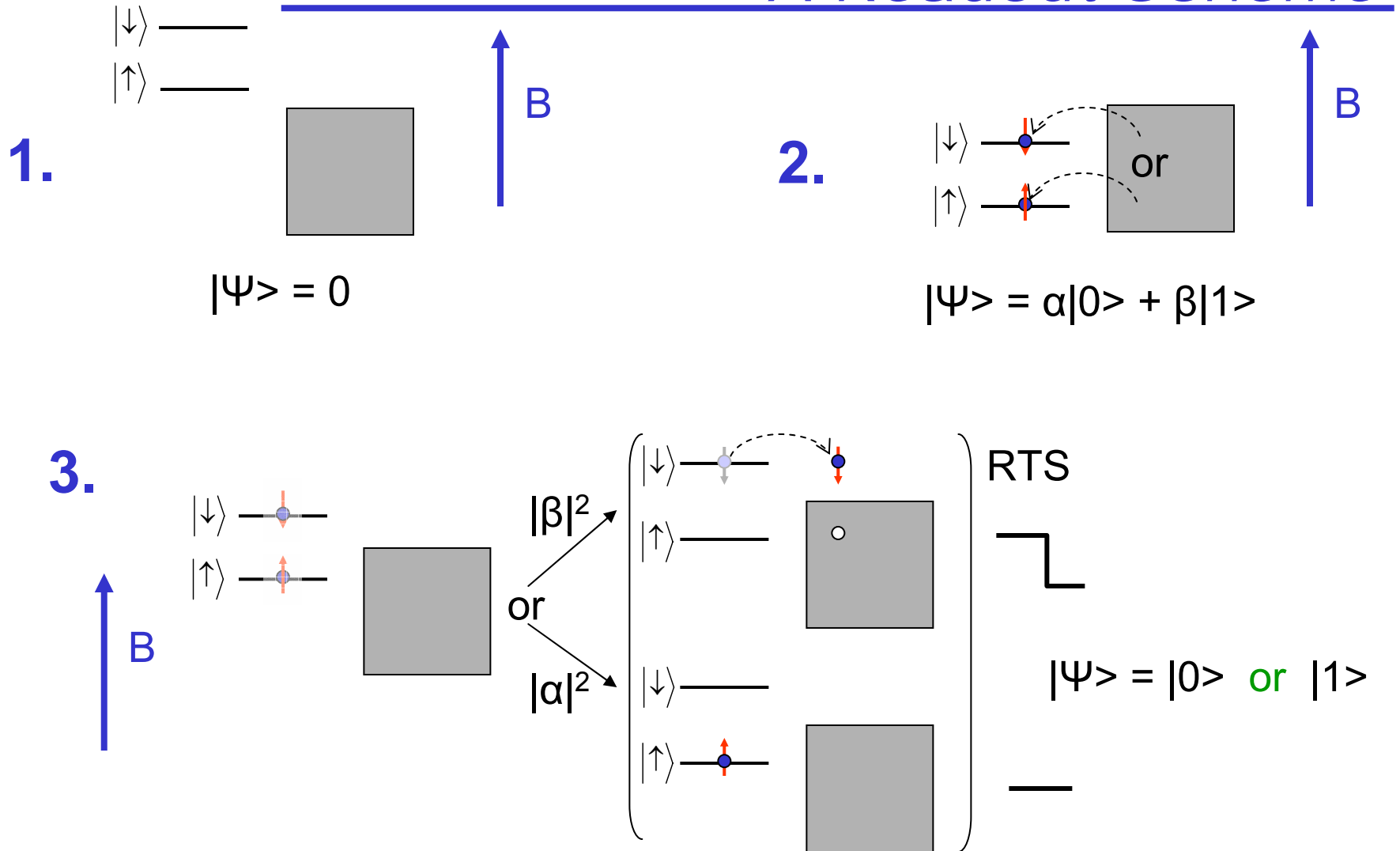
obtained after the time-domain analysis

Surprise 1: Signal changes sign for larger microwave power!



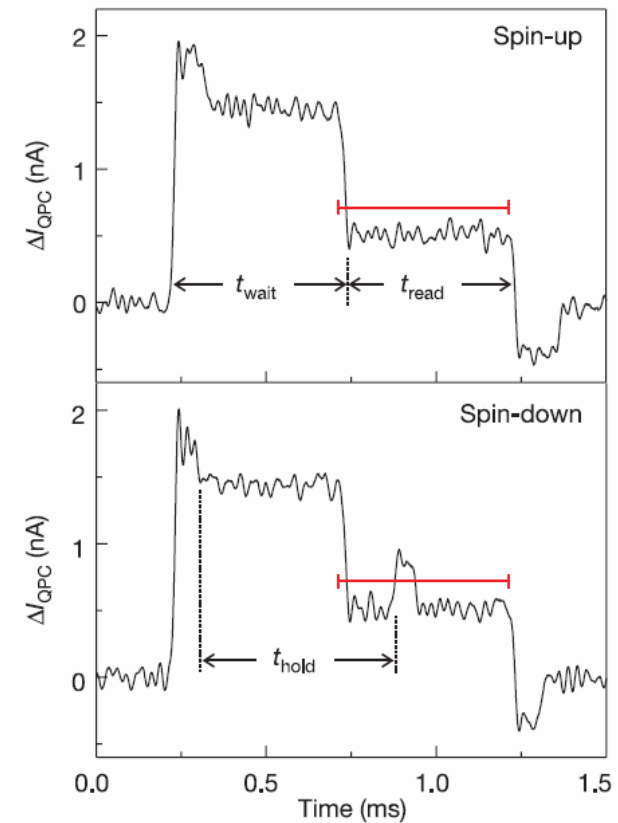
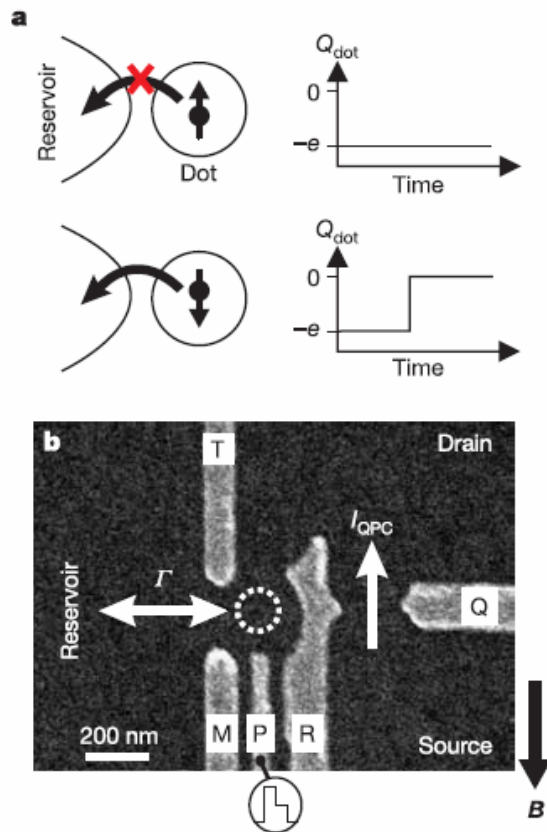
- *Signal changes sign when $\Gamma \sim \omega_{\text{Rabi}}$*
- *Improved signal-to-noise*
- *Tunneling rate is reduced on the resonance*

Traps for Quantum Computing A Readout Scheme



Single Spin Measurement in Quantum Dots

Elzerman et al., *Nature* **431**, 430 (2004)



Demonstrated Spin Measurement Efficiency ~ 65%

The Readout Scheme: Experimental Facts

The scheme works in quantum dots with 65% efficiency
REF: J.M. Elzerman *et al.*, Nature **430**, 431(2004).

So far in FET traps the scheme does not work – no RTS signal

WHY? => spin is always in its ground state.

WHY? => fast spin relaxation => WHY?

*Maybe because of the exchange interaction with electrons
in the conduction channel ?!*

Need to look at the microscopic structure of traps!

Introduction: Single Spin Magnetic Resonance

Random Telegraph Noise in Field Effect Transistors

- *A scheme for Electron Spin Resonance: Theory*
- *A scheme for Electron Spin Resonance: Experiment*
- *Single spin Detection*

Inconsistency between expected and observed tunneling rates: Polaronic slowdown

Low temperature magnetic anomalies: Possible Kondo Effect

Summary and Open problems

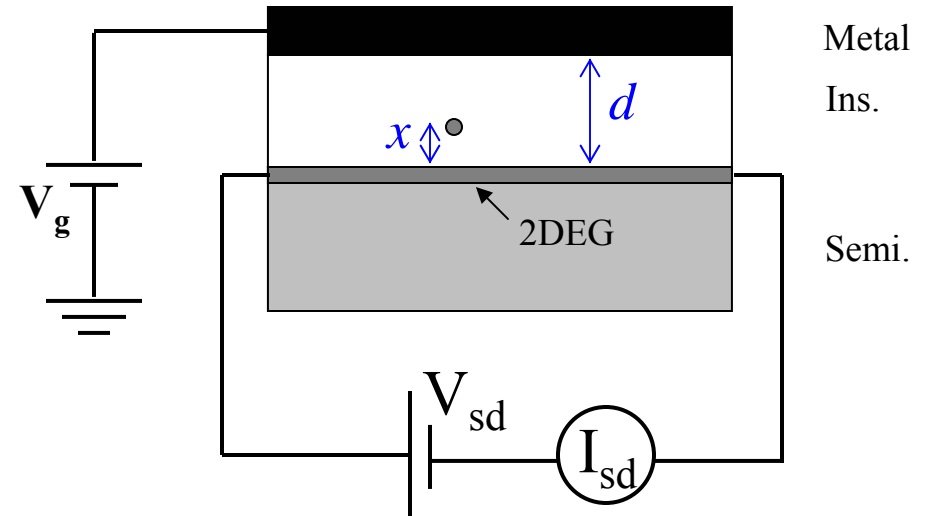
Determination of Defect's Position. *Surprise II*

Experimentalists can measure the location of the trap (x) with respect to the conduction channel.

Defect position determination:

$$\frac{\tau_{in}}{\tau_{out}} = \frac{\exp[(E_d - \mu)/T]}{1} = \exp\left(\frac{V_g - V_{g0}}{T} \frac{x}{d}\right)$$

One finds $x \sim 1-3 \text{ \AA}$.

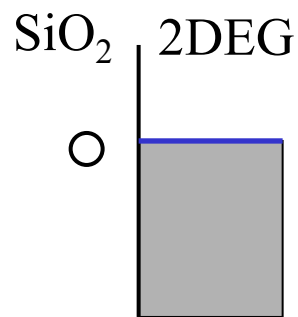
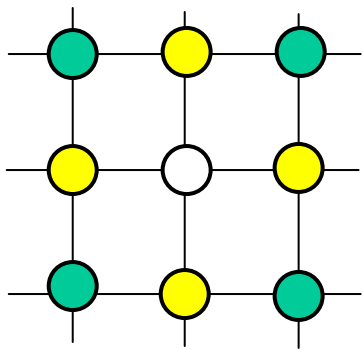


Estimate for tunneling time yields \sim (ps – ns)

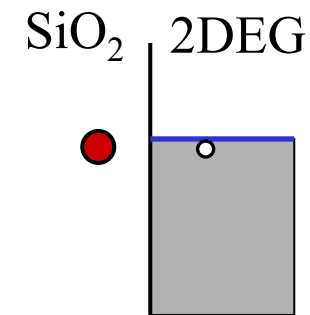
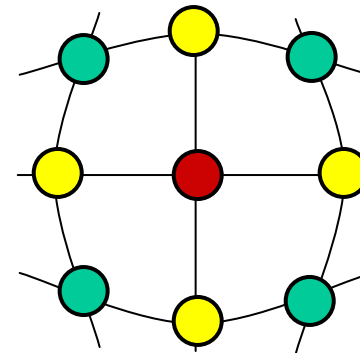
Observed \sim (ms – s) ???

SiO_2 is a polar crystal \Rightarrow strong coupling to optical phonons

Empty Trap



Trap with an extra electron



$+ e^-$

Tunnel rate in the presence of lattice deformations

$$H = \sum_k E_k c_k^\dagger c_k + E_0 d^\dagger d + d^\dagger d g (a^\dagger + a) + \omega_0 a^\dagger a + \Delta \sum_k (c_k^\dagger d + d^\dagger c_k) + V d^\dagger d \sum_{k,k'} c_k^\dagger c_{k'}$$

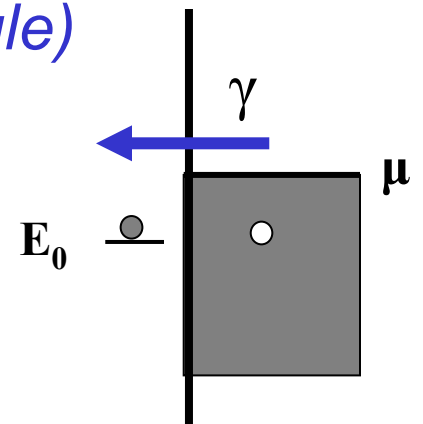
↑ conduction electrons
 ↑ defect level
 ↑ electron-phonon interaction
 ↑ optical phonon
↑ tunneling (H_T)
↑ Coulomb interaction

Calculation of Tunnel Rate for $V = 0$ (Golden Rule)

$$\gamma^{GR} = 2\pi \sum_{\text{final states}} |\langle \text{initial} | H_T | \text{final} \rangle|^2 \delta(E_{\text{initial}} - E_{\text{final}})$$

$$|\text{initial}\rangle = |0\rangle_{\text{electrons}} \otimes |0\rangle_{\text{phonon}}$$

$$|\text{final}\rangle = |1_k\rangle_{\text{electrons}} \otimes |n\rangle_{\text{shifted phonon}}$$



Estimate for Si Field Effect Transistor

Mozyrsky, Martin, Shnirman cond-mat/0312503

$$\Gamma = 2\pi\nu\Delta^2 e^{-\frac{E_p}{\omega_0}}$$

Assuming Fröhlich electron-phonon coupling

$$E_p = 5e^2 / (16a_d) (\epsilon_\infty^{-1} - \epsilon_0^{-1})$$

For SiO₂ $\epsilon_0 = 4$, $\epsilon_\infty = 2$, $a_d \sim 1 \text{ \AA}$ $\rightarrow E_p \approx 1.2 \text{ eV}$

For bulk optical phonons in SiO₂: $\omega_0^{\text{bulk}} \approx 60 \text{ meV}$

$$\exp(-E_p / \omega_0) \sim \exp(-20) \sim 10^{-8}$$

Qualitative agreement with observed rates !
Strong electron-phonon interaction is responsible
for long tunneling time in Si FET

Introduction: Single Spin Magnetic Resonance

Random Telegraph Noise in Field Effect Transistors

- *A scheme for Electron Spin Resonance: Theory*
- *A scheme for Electron Spin Resonance: Experiment*
- *Single Spin Detection*

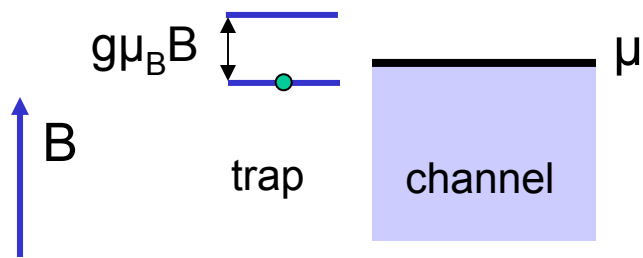
Inconsistency between expected and observed tunneling rates: Polaronic slowdown

Low temperature magnetic anomalies: Possible Kondo Effect

Summary and Open problems

Magnetic field dependence at low temperatures. *Surprise III*

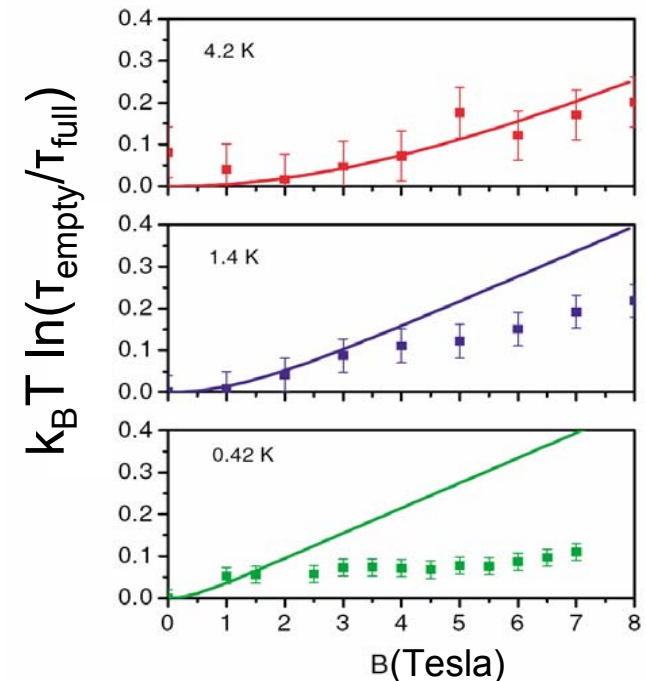
Xiao et al., Phys. Rev. Lett. 91, 078301 (2003)



For a paramagnetic spin
 $(T_{\text{empty}}/T_{\text{full}}) \approx \exp(g\mu_B B / k_B T)$

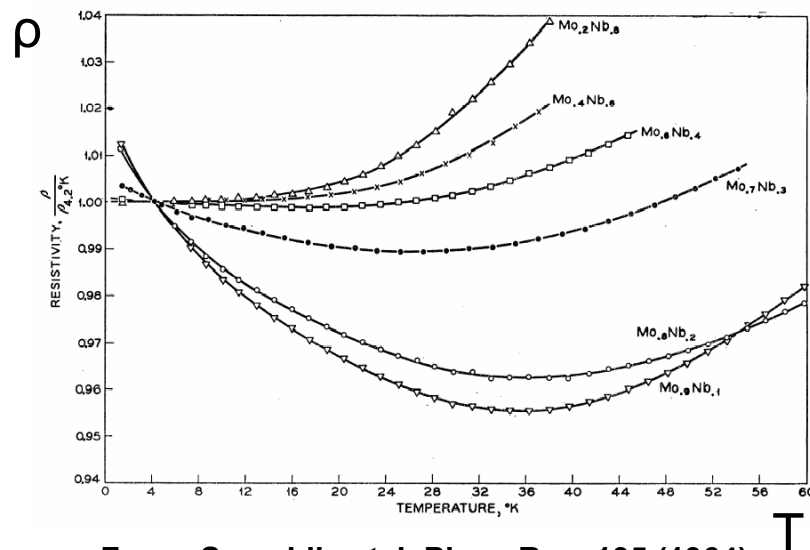
*No agreement between simple model
and experiment at low T!*

Kondo effect?



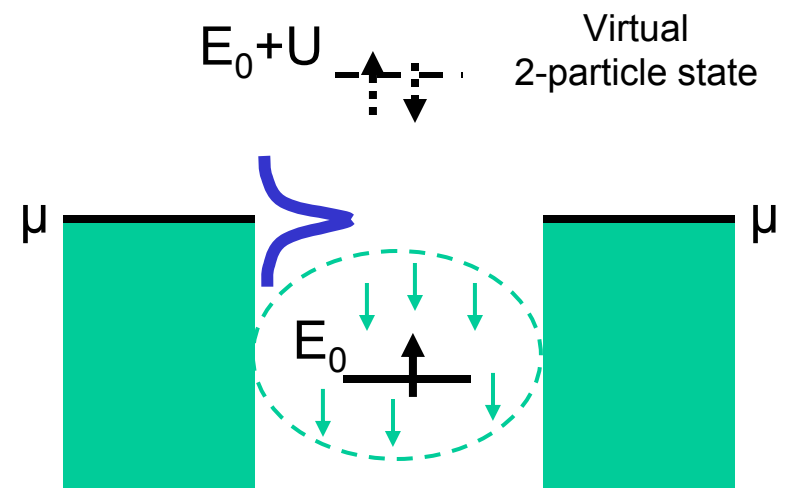
Solid lines: theoretical fits for a
paramagnetic trap
Bullets: experimental data

Resistivity of metals doped with magnetic impurities



From: Sarachik, et al, Phys. Rev. 135 (1964)

Magnetic impurity in a metal

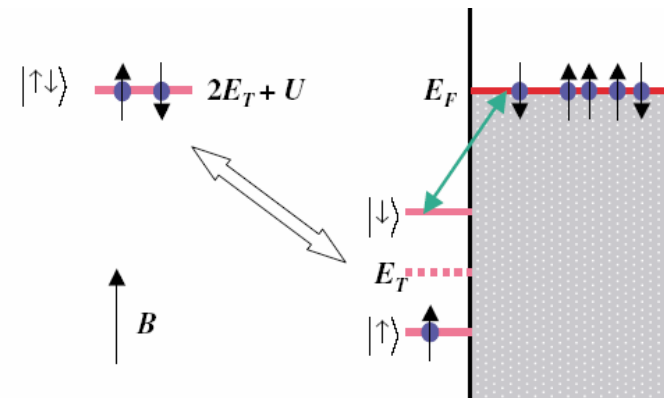


A localized impurity spin is screened by spins of conduction electrons

At low energy scale (below T_K) the magnetic impurity creates a strong resonance at Fermi surface \Rightarrow scattering \Rightarrow resistivity

$$T_K \sim \exp[-O(1) U/\Gamma]$$

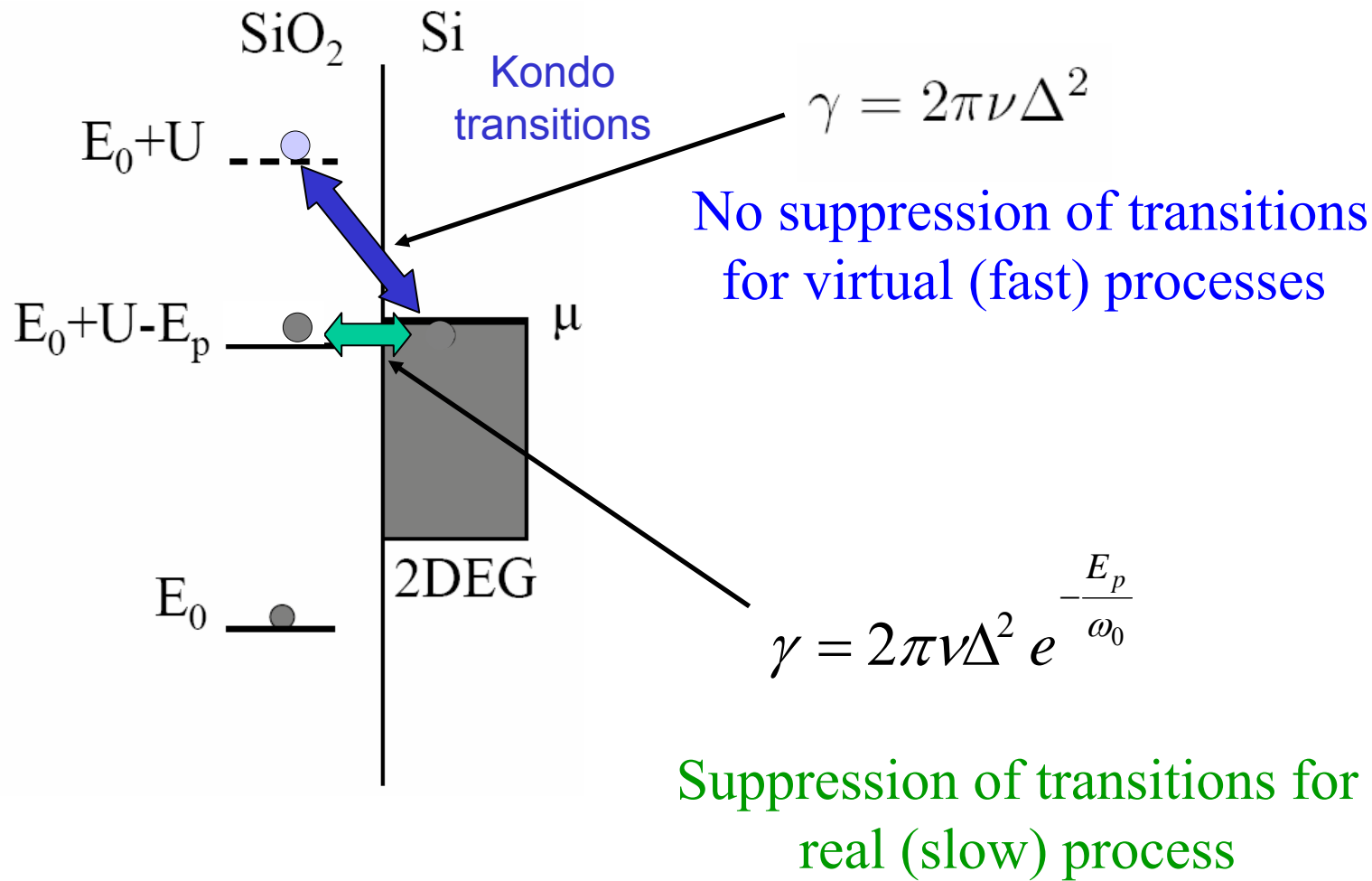
$$\text{For } \Gamma \sim 1 \text{ s}^{-1} \Rightarrow T_K \rightarrow 0$$



However, Γ is small only effectively – due to strong electron-lattice coupling! The “bare” hybridization (“bare” Γ_0) may be strong!

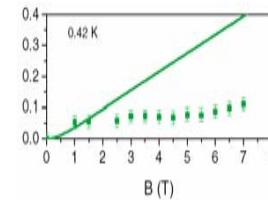
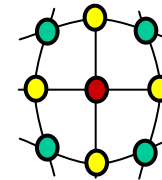
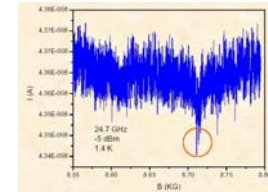
$$\Gamma = \underbrace{2\pi\nu\Delta^2}_{\text{bare } \Gamma_0} e^{-\frac{E_p}{\omega_0}}$$

Large bare Γ_0 relevant for Kondo if $U > \omega_0 \rightarrow$ finite T_K



Summary and Perspectives

- *Single electron spin resonance in FET*
- *Tunneling slowdown (due to strong electron-lattice coupling)*
- *Kondo Effect in FET traps ?*
- *ESR signal inversion ?*



What's next?

A single nuclear spin?...

